

# United States Patent and Trademark Office



UNITED STATES DEPARTMENT OF COMMERC United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.usplo.gov

APPLICATION NO	D. F	ILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/786,890	10/786,890 02/25/2004		Yoshio Shimoaka	81880.0114	3529
26021	7590	10/19/2006		EXAMINER	
		SON L.L.P.	LUU, CHUONG A		
1999 AVE Suite 14		HE STARS		ART UNIT	PAPER NUMBER
	ELES, CA	90067	2818		

DATE MAILED: 10/19/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No.	Applicant(s)			
Office Actio		10/786,890	SHIMOAKA, YOS	HIO		
Office Actio	on Summary	Examiner	Art Unit			
		Chuong A. Luu	2818			
The MAILING DA Period for Reply	TE of this communication app	pears on the cover sheet with the c	correspondence ad	ldress		
WHICHEVER IS LONG  - Extensions of time may be ava after SIX (6) MONTHS from the  - If NO period for reply is specification  - Failure to reply within the set of	ER, FROM THE MAILING D ilable under the provisions of 37 CFR 1.1 e mailing date of this communication. ed above, the maximum statutory period of r extended period for reply will, by statute e later than three months after the mailin	Y IS SET TO EXPIRE <u>03</u> MONTH ATE OF THIS COMMUNICATIOI 36(a). In no event, however, may a reply be tir will apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONE g date of this communication, even if timely filed	N. nely filed the mailing date of this c D (35 U.S.C. § 133).			
Status						
2a)☐ This action is <b>FIN</b> 3)☐ Since this applica	tion is in condition for allowa	2006.  action is non-final.  nce except for formal matters, pro  x parte Quayle, 1935 C.D. 11, 4		e merits is		
Disposition of Claims						
4a) Of the above of 5) ☐ Claim(s) is 6) ☑ Claim(s) <u>1-6</u> is/ard 7) ☐ Claim(s) is	e rejected.	n from consideration.				
_						
10) The drawing(s) file  Applicant may not re  Replacement drawi	equest that any objection to the ng sheet(s) including the correct	er.  epted or b) objected to by the drawing(s) be held in abeyance. Se ion is required if the drawing(s) is obtaining. Note the attached Office	e 37 CFR 1.85(a). ejected to. See 37 C			
Priority under 35 U.S.C. §	119					
<ul> <li>12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).</li> <li>a) All b) Some * c) None of:</li> <li>1. Certified copies of the priority documents have been received.</li> <li>2. Certified copies of the priority documents have been received in Application No</li> <li>3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).</li> <li>* See the attached detailed Office action for a list of the certified copies not received.</li> </ul>						
Attachment(s)		_				
1) 🔀 Notice of References Cited ( 2) 🔲 Notice of Draftsperson's Pat	PTO-892)	4) Interview Summary Paper No(s)/Maił D				
B) Information Disclosure State Paper No(s)/Mail Date 9/1/2	ment(s) (PTO-1449 or PTO/SB/08)	5) Notice of Informal F 6) Other:		O-152)		

#### **DETAILED ACTION**

## Response to Arguments

Applicant's arguments with respect to claims 1-6 have been considered but are most in view of the new ground(s) of rejection.

#### **PRIOR ART REJECTIONS**

### **Statutory Basis**

# Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

## The Rejections

Claims 1-2 and 4-6 are rejected under 35 U.S.C. 102(b) as being anticipated by Ishiguro Takashi (JP2001-015909).

Ishiguro Takashi discloses a solder bump apparatus with

(1); (4) a print mask used to form bumps on barrier metal layers of a wafer comprising a plurality of elongated perforations disposed in linear arrangement for applying a paste via the perforations onto an object of printing,

Application/Control Number: 10/786,890 Page 3

Art Unit: 2818

wherein each of said perforation includes an edge disposed along the longitudinal direction, said edge being inclined with respect to the direction perpendicular to the direction of arranging the perforations (see drawings 2 and 6);

- (2) wherein the edge of said perforation disposed along the longitudinal direction thereof is substantially straight (see drawing 2);
- (5) wherein said perforations are disposed in a plurality of rows and the density of said perforations is set individually for each row (see drawing 2);
- (6) wherein the rows of said perforations are disposed substantially in parallel to each other (see drawing 2).

# **PRIOR ART REJECTIONS**

## **Statutory Basis**

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

#### The Rejections

Claim 3 is rejected under 35 U.S.C. 103(a) as being unpatentable over Ishiguro Takashi (JP2001-015909).

Ishiguro Takashi teaches everything above except for wherein the edge disposed along the longitudinal direction of said perforations is inclined by an angle from 5 to 45° from the direction perpendicular to the direction of arranging said perforations. However, wherein the edge disposed along the longitudinal direction of said perforations is inclined by an angle from 5 to 45° from the direction perpendicular to the direction of arranging said perforations being within the range is considered to be obvious. Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify wherein the edge disposed along the longitudinal direction of said perforations is inclined by an angle from 5 to 45° from the direction perpendicular to the direction of arranging said perforations of Ishiguro Takashi's device within the range as claimed for the purpose of providing for reduced power consumption and increase operational speed, and it also has been held that where the general conditions of a claim are disclosed in the prior ad, discovering the optimum or workable ranges involves only routine skill in the art and it is noted that the applicant does not disclose criticality in the ranges claimed. In re Aller, 105 USPQ 233 (see MPEP j 2144.05).

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Chuong A. Luu whose telephone number is (571) 272-1902. The examiner can normally be reached on M-F (6:15-2:45).

Application/Control Number: 10/786,890

Art Unit: 2818

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith can be reached on (571) 272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Chuong Anh Luu Patent Examiner October 13, 2006 Page 5